Project of the station "Fast Processes" at the source of synchrotron radiation SKIF

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A national source of synchrotron radiation of the 4th generation with an energy of 3 GeV SKIF will be built at the Novosibirsk Scientific Center. "Fast Processes" is one of six first priority beamlines that are planned for construction within this project. The main task of the station "Fast Processes" is to carry out experiments with characteristic scales of process change from pico to microseconds.